SHEET 1 OF 1 Form PTO 1449 S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE ATTY DOCKET NO. SERIAL NO. 294550US0PCT 10/588.703 APPLICANT LIST OF REFERENCES CITED BY APPLICANT Jean DIJON, et al. FILING DATE GROUP August 8, 2006 U.S. PATENT DOCUMENTS EXAMINER DOCUMENT SUR FILING DATE DATE NAME CLASS INITIAL NUMBER CLASS IF APPROPRIATE AA 2003 0234417 12-25-03 RAAIJMAKERS, Ivo et al. MLP/ AB 5 084 144 J1-28-92 MIP/ REDDY, N. R. K. et al. AC. AD ΑF AF AG AH ΑI AJ AK AL AM AN FOREIGN PATENT DOCUMENTS DOCUMENT TRANSLATION DATE COUNTRY NUMBER YES M.L.P in English AO 03 027011 04-03-03 wo NO 96 22841 in English AP 08-01-96 wo MIP/ NO ΑQ AR AS AT ΑU OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.) YUDASAKA, Masako et al., "Specific Conditions for Ni Catalyzed Carbon Nanotube Growth by Chemical Vapor Deposition", Applied Physics Letters, Vol. 67, No. 17, pgs. 2477-2479, 1995. October Δ١/ /M.I.P./ COTTEL, C. M. et al.," Microstructual Development of Thin Films Grown by Pulsed Laser Deposition", Materials Science and Engineering B, Vol. 32, No. 3, pgs. 221-230, 1995 (no month) SIEGAL, M. P. et al.," Precise Control of Multiwall Carbon Nanotube Diameters Using Thermal Chemical Vapor Deposition", Applied Physics Letters, Vol. 80, No. 12, pgs. 2171-2173, 2002. March GAO, J. S. et al.," Plasma Breaking of Thin Films into Nano-Sized Catalysts for Carbon Nanotube Synthesis", Materials Science and Engineering A, Vol. 352, pgs. 308-313, 2003.
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